SOILS AND FOUNDATIONS

Editor

Akira Murakami, *Kyoto University*

Associate Editors

Yoshiaki Kikuchi, *Tokyo University of Science*
Jun Otani, *Kumamoto University*

Exective Board

Hirokazu Akagi, *Waseda University*
Akira Kobayashi, *Kansai University*
Takeshi Kodaka, *Meijo University*
Yoshihisa Miyata, *National Defence Academy*
Shin-ichi Nishimura, *Okayama University*
Satoru Ohtsuka, *Nagaoka University of Technology*
Takashi Okayasu, *Kyusyu University*
Takao Seki, *Maebashi Institute of Technology*
Ryosuke Uzuoka, *The University of Tokushima*
Giulia Viggiani, *University of Rome Tor Vergata*

Editorial Board

Giovanna Biscontin, *Texas A&M University, USA*
Kenichi Horikoshi, *Taisei Corporation*
Toru Inui, *Kyoto University*
Kazuhiro Kaneda, *Takenaka Corporation*
Katsuyuki Kawai, *Kobe University*
Mamoru Kikumoto, *Yokohama National University*
Sayuri Kimoto, *Kyoto University*
Takashi Kiyota, *The University of Tokyo*
Shun-ichi Kobayashi, *Kanazawa University*
Noriyuki Kobayashi, *Ehime University*
Takashi Matsushima, *University of Tsukuba*
Tsutomu Namikawa, *Shibaura Institute of Technology*
Shinji Sassa, *Port and Airport Research Institute*
Tom Schanz, *Ruhr University*
Makoto Suzuki, *Shimizu Corporation*
Mutsumi Tashiro, *Nagoya University*
Yoshimichi Tsukamoto, *Tokyo University of Science*
Richard Wan, *University of Calgary*
Yuki Yamakawa, *Tohoku University*
Hideaki Yasuhara, *Ehime University*

International Advisory Board

J. Atkinson, *City University, UK*
A. S. Balasubaramaniam, *Griffith University, Australia*
M. D. Bolton, *University of Cambridge, UK*
H. di Benedetto, *ENTPE/DGCB, France*
J. M. Duncan, *Virginia Polytechnic Institute and State University, USA*
W. D. L. Finn, *University of British Columbia, Canada*
S. Frydman, *Israel Institute of Technology, Israel*
G. Gudehus, *University of Karlsruhe, Germany*
X.-Y. Hou, *Tongji University, China*
G. T. Houlsby, *University of Oxford, UK*
M. Jamiolkowski, *Politecnico di Torino, Italy*
R. J. Jardine, *Imperial College, UK*
P. V. Lade, *Catholic University of America, USA*
D. Leshchinsky, *University of Delaware, USA*
J. K. Mitchell, *Virginia Polytechnic Institute and State University, USA*
D. Muir Wood, *University of Dundee, UK*
M. F. Randolph, *University of Western Australia, Australia*
R. K. Rowe, *Queen's University, Canada*